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(21) 国際出願番号PCT/JI(22) 国際出願日1998年8月25日(30) 優先権データ1997年8月28日(28.08.97)(71) 出願人(米国を除くすべての指定国について)メルシャン株式会社(MERCIAN CORPORATION)[JP/J]〒104-8305 東京都中央区京橋一丁目5番8号 Tokyo, (J(72) 発明者;および(75) 発明者/出願人(米国についてのみ)城道 修(JOHDO, Osamu)[JP/JP]〒252-0804 神奈川県藤沢市湘南台4-27-11ヴィラハイツ湘南203 Kanagawa, (JP)井口このみ(IGUCHI, Konomi)[JP/JP]〒253-0073 神奈川県茅ヶ崎市中島1143エスペランサ湘南101 Kanagawa, (JP)吉岡武男(YOSHIOKA, Take0)[JP/JP]〒252-1124 神奈川県綾瀬市吉岡1782-10 Kanagawa, (JI)	 67 (74) 代理人 并理士 小田島平吉,外(OE 〒107-0052 東京都港区赤坂 日本自転車会館 小田島特許 JP (81) 指定国 AU, CA, CN 許 (AT, BE, CH, CY, DE, DK MC, NL, PT, SE). 添付公開書類 国際調査報告書 	DAJIMA, Heikichi et al.) 1丁目9番15号 F事務所 Tokyo, (JP) , CZ, HU, JP, KR, RU, US, 欧州特 , ES, FI, FR, GB, GR, IE, IT, LU,	

(54)Title: METHOD OF PURIFYING DAUNOMYCIN

(54)発明の名称 ダウノマイシンの精製方法

(57) Abstract

A method which comprises adsorbing daunomycin from crude daunomycin onto a hydrophobic porous synthetic resin support, eluting the daunomycin with a buffered aqueous solution containing a water-miscible organic solvent, and recovering the purified daunomycin. Thus, daunomycin (daunorubicin) is efficiently purified.

本明細書は、粗精製ダウノマイシンからダウノマイシンを吸着させた 疎水性多孔質合成樹脂担体を水混和性有機溶媒を含有する緩衝化された 水性溶液でダウノマイシンを溶出し、精製されたダウノマイシンを回収 する方法に関する。効率よくダウノマイシン(ダウノルビシン)が精製 される。

PCTに基づいて公開される国際出願のパンフレ	ット第一頁に掲載されたPCT加盟国を同定するために使用されるコー	・ド(参考情報)
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DESCRIPTION

METHOD OF PURIFYING DAUNOMYCIN

5 Technical Field

The present invention relates to a purifying method for obtaining a high purity product of daunomycin which is an anthracycline antibiotic.

10 Background Art

It is known that daunomycin (called as well daunorubicin) is obtained from a culture medium for ray fungus, and it is an anthracycline antibiotic which has a wide range anticancer spectrum against experimental tumor (refer to U.S. Patent 3,616,242). As a

15 matter of fact, it is widely used as a cancer chemotherapeutic agent for a clinical purpose.

Analogous anthracycline antibiotics including daunomycin (hereinafter abbreviated as "DM") are further purified by treating products roughly purified from the culture medium described above

20 with a cation exchange resin (for example, Amberlite[™] IRC 50) and eluting them with a sodium chloride-containing aqueous solution or methanol containing sodium chloride (Japanese Patent Publication No. 44347/1974 and Japanese Patent Application Laid-Open No. 15880/1975). Further, published as well are methods comprising the

- 25 steps of adsorbing the antibiotic described above onto a polymeric ion exchange resin (for example, Amberlite[™] ER 180) or a CM Sepharose rose resin (for example, Sepharose[™] CHB) and then eluting it with a mixture of acidic water and a polar solvent (Japanese Patent Application Laid-Open No. 118797/1984 and Japanese Patent Publication
- 30 No. 39476/1992 originating therein, divisionally filed Japanese Patent Application Laid-Open No. 252291/1995, and U.S. Patent

4,861,870 corresponding to them). Further, it is described as well in the latter official gazettes that a roughly purified anthracycline antibiotic is adsorbed onto an adsorptive porous synthetic resin carrier (for example, AmberliteTM XAD2) at a pre-purifying step

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before treating with the polymeric ion exchange resin described above, and the antibiotic described above is then eluted with a mixture of water/methanol (5 : 1) (v/v).

It seems that DM having a fixed high purity can be obtained according to the conventional adsorbing and eluting tech-

- 10 niques described above. However, the more the high purity product is tried to obtain, the more the recovery percentage of intended DM is reduced. In contrast with this, the more the recovery percentage is tried to enhance, the more the purity of the product can not be elevated. In particular, when trying to recover DM from a culture
- 15 medium, purified DM tends to be accompanied with impurities (for example, those having a longer retention time than that of DM in HPLC analysis which shall be described later) which are difficult to be removed at purifying steps including crystallization subsequent thereto.

Accordingly, an object of the present invention is to provide a purifying method in which high purity DM can be obtained from starting crude DM at a high yield in a simple manner.

Disclosure of the Invention

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The present inventors have found that DM having a high purity can be obtained at a high yield by using an adsorptive (or hydrophobic) synthetic resin carrier which is used at a preliminary purifying step prior to treatment using an ion exchange resin (for example, AmberliteTM ERI 180) for obtaining a high purity product and by selecting specific elution (or dissolution) conditions. It shall

be quite surprising that the problems described above can be solved

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only by using a hydrophobic synthetic resin carrier which is merely used at a preliminary purifying step where an ion exchange resin is inevitably used in order to obtain a high purity product as described in, for example, Japanese Patent Application Laid-Open No. 118797/ 1084 described above

5 1984 described above.

Hence, according to the present invention, provided is a purifying method of daunomycin characterized by eluting daunomycin from a hydrophobic porous synthetic resin carrier onto which daunomycin is adsorbed from crude daunomycin with an aqueous

10 solution which contains a water-miscible organic solvent and which is buffered to pH 2.5 to 6 and recovering purified daunomycin from the eluent.

Brief Description of the Drawings

15 Fig. 1 A to 1C are graphs showing the recovery rates, the recovered liquid amounts and the relative purities of DM in Examples 1 to 8.

Control (pH 2.5), pH 2.5, pH 3.0, pH 3.5, pH 4.0, pH 4.5, pH 5.0 and pH 6.0 on the basis of an abscissa in the drawing corre-20 spond respectively to the results of Examples 1 to 8.

Fig. 2 is a chart showing the result of an HPLC analysis of low purity DM powder (relative purity: 80.3 %) which is a starting material.

Fig. 3 is a chart showing the result of a solution of DM
25 (relative purity: 88 % or more) obtained in Example 5 (present invention).

Fig. 4 A to 4C are graphs showing the recovery rates, the recovered liquid amounts and the relative purities of DM in Examples 9 to 17.

30 Fig. 5 A to 5C are graphs showing the recovery rates, the recovered liquid amounts and the relative purities of DM in Exam-

ples 18 and 19.

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Fig. 6 is an HPLC analysis chart of raw material DM having a higher purity (relative purity: 95.5 %) used in Examples 9 to 19.

Fig. 7 is an HPLC analysis chart of fractions having a relative purity of 98 % or more in Examples 9 to 19.

Best Mode for Carrying Out the Invention

The crude daunomycin (DM) used in the present invention may have any content of DM as long as clusters and other solid matters are removed from a culture medium containing DM according to a known separating or purifying method and DM is concentrated to some extent. The methods introduced as the conventional techniques described above are included as well in such separating or

purifying method, and DM-containing products having a relatively low purity obtained via those methods are included as well. Further, a DM-containing treated product accompanying fixed impurities obtained through a semi-synthetic process, if it corresponds thereto, is included as well in the crude DM used in the present invention.

However, the present invention can more efficiently be applied when DM has a relative purity of about 80 % or more, preferably 80 to 96 %. The "relative purity" used in the present specification means a proportion of a peak area originating in DM to the whole peak areas showing the elution behaviors of the respective components obtained as result of subjecting the sample to HPLC analysis which shall be described later.

The hydrophobic porous synthetic resin carrier used for adsorbing crude DM may be of any kinds as long as it has functions

30 cific, a porous polymer obtained by polymerizing styrene with divinylbenzene by a specific method. Such porous polymers are different in

meeting the object of the present invention and includes, to be spe-

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a specific surface area and a pore volume depending on the production methods but shall not be restricted by those physical properties as long as the prescribed effects can be obtained by using them in the specific examples of the present invention which shall be described later.

5 later.

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In general, however, the porous polymer having a specific surface area falling in a range of 400 to 800 m²/g and a pore volume falling in a range of 0.650 to 1.5 ml/g can suitably be used. Such porous polymer can be selected as well from commercially available products and shall not be restricted. DiaionTM HP20 (hereinafter abbreviated as HP20) or HP20SS (hereinafter abbreviated as HP20SS) manufactured by Mitsubishi Chemical Corporation can

advantageously be used.

As described above, according to the present invention, 15 DM is eluted from the hydrophobic porous synthetic resin carrier onto which crude daunomycin is adsorbed by using an aqueous solution which contains a water-miscible organic solvent and which is buffered to pH 2.5 to 6. The water-miscible organic solvent shall not specifically be restricted as long as it meets the object of the present

20 invention and includes methanol, ethanol, isopropanol and acetone as a solvent having both a profitability and an elution effect. Among them, methanol and acetone are particularly suited. When such solvents are used, an optimum mixing ratio of these solvents to the aqueous solution is varied depending on the kind of the solvents used

and therefore shall not be restricted but, in general, they can be used in a proportion of the solvent to the aqueous solution of 80 : 20 to 20 :
80 in terms of a volume basis. For example, when methanol is used, methanol and the aqueous solution can be used in a proportion of 60 to 80/20 to 40, particularly about 70/about 30, and when acetone is

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used, acetone and the aqueous solution can be used in a proportion of 20 to 40/80 to 60, particularly about 30/about 70.

The aqueous solution containing these solvents has to be buffered particularly to pH 2.5 to 6. In general, the pH of lower than 2.5 tends to reduce the relative purity of DM in the resulting product. On the other hand, the pH exceeding 6 tends to lower the recovering

- 5 rate of DM. The buffer agent used for buffering may be any buffer agents as long as they do not exert an adverse effect on the product. Such buffer agent shall not be restricted but includes potassium biphthalate-HCl, glycolic acid-HCl, sodium citrate-HCl, potassium citrate-HCl, potassium citrate-citric acid, succinic acid-Na₂B₄O₇,
- 10 sodium acetate-HCl, sodium acetate-acetic acid, citric acid-Na₂HPO₄, tartaric acid-sodium tartarate, lactic acid-sodium lactate, aconitinic acid-NaOH and succinic acid-NaOH. Among them, sodium citrate-HCl is particularly preferred.

The usable concentration of the buffer agent is 0.05M to 15 1M depending on the kind of the buffer agents used, and in a system of sodium citrate-HCl which is the preferred example, about 0.1M sodium citrate is suitably used.

An operation temperature at which DM adsorbed on the resin carrier described above is eluted therefrom may be any temper-20 ature as long as it does not exert an adverse effect such as degradation on DM or the resin carrier, but it is advantageously in the vicinity of a room temperature (10 to 30°C). Further, such resin carrier is used usually in the form of a column into which it is charged, but the form shall not be restricted thereto.

In the preparation of the hydrophobic porous synthetic resin carrier onto which crude DM is adsorbed, DM may be adsorbed onto the resin carrier described above by any method as long as it does not exert an adverse effect on the elution described above. To be specific, however, it is prepared preferably by contacting a solution

30 obtained by dissolving crude DM in an acidic aqueous solution (hereinafter referred to as acidic water) having a pH of about 1 to 5 with

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the carrier described above to thereby adsorb DM onto the carrier and then washing the DM-adsorbed resin carrier with the acidic water described above. The acidic water used for dissolving crude DM may be the same as or different from the acidic water used for

- 5 washing the DM-adsorbed resin carrier. The pH of the acidic water may be controlled merely with hydrochloric acid but may be controlled with such buffer agents as described above. A 0.1M citric acid aqueous solution can preferably be used. The pH of the acidic water is controlled particularly preferably to the vicinity of about 2.5. Such
- 10 washing with the acidic water is continued until impurities are not found to be present in the washing solution. The presence of the impurities in the washing solution can be confirmed by means of, for example, a spectrophotometer.

DM purified by the method of the present invention 15 described above may be treated repeatedly, if necessary, by the preceding method comprising the same or different structure.

Further, in the recovery of DM from the DM-containing fraction purified by the method described above, DM may be recovered from a solution obtained by distilling off the organic solvent by a

- 20 conventionally known extracting method in which chloroform is used. However, preferred is a method in which the fractions having a relative purity of a fixed value or more are collected; the solution is adjusted to a pH of about 8.5 with sodium hydroxide, and about a half amount of chloroform based on the amount of the solution is added to
- extract DM; the organic solvent phase is concentrated and dried under reduced pressure, and then a small amount of chloroform/methanol (20 : 1) is added thereto to dissolve it; and then this solution is added to an excess amount of hexane to precipitate DM, and precipitated DM is filtered, whereby DM having a higher grade
 can be recovered.

The present invention shall more specifically be explained

below with reference to specific examples, but these examples are provided for the purpose of facilitating to understand the present invention and the actions and the effects of the present invention. <u>Example 1</u> (comparative example): purification of low purity DM

- Low purity DM powder of 500 mg (a DM content of 305 mg and a relative purity of 80.3 %) was dissolved in 200 ml of acidic water (pH 2.5, HCl), and this solution was passed through an HP20 column (50 ml). After washing the column with 50 ml of the same acidic water, DM was eluted with methanol-acidic water (pH 2.5)
- 10 (70:30), and the DM-eluted fractions were subjected to HPLC analysis. The DM fractions having relative purities of 86, 88, 89 and 90 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as controls (pH 2.5) in Fig. 1A to 1C.

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HPLC analytical conditions:

Column: ULTRASPHERE ODS, 250×4.6 mm i.d. (Beckman) Moving phase: water-acetonitrile (62 : 38), pH adjusted to 2.2 ± 0.2 with phosphoric acid

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Flow velocity: 1.5 ml/min. Detection: 495 nm

Example 2 (present invention): purification of low purity DM

Low purity DM powder of 500 mg (a DM content of 305 mg and a relative purity of 80.3 %) was dissolved in 200 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 2.5), DM was eluted with a methanol-0.1M citric acid buffer solution (pH

30 2.5) (70: 30), and the DM-eluted fractions were subjected to HPLC analysis. The DM fractions having relative purities of 86, 88, 89 and

90 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as pH 2.5 in Fig. 1A to 1C.

Example 3 (present invention): purification of low purity DM

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- Low purity DM powder of 500 mg (a DM content of 305 mg and a relative purity of 80.3 %) was dissolved in 200 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 3.0),
- 10 DM was eluted with a methanol-0.1M citric acid buffer solution (pH 3.0) (70:30), and the DM-eluted fractions were subjected to HPLC analysis. The DM fractions having relative purities of 86, 88, 89 and 90 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of

DM are shown as pH 3.0 in Fig. 1A to 1C.
 Example 4 (present invention): purification of low purity DM

Low purity DM powder of 500 mg (a DM content of 305 mg and a relative purity of 80.3 %) was dissolved in 200 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20

- 20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 3.5), DM was eluted with a methanol-0.1M citric acid buffer solution (pH 3.5) (70 : 30), and the DM-eluted fractions were subjected to HPLC analysis. The DM fractions having relative purities of 86, 88, 89 and
- 90 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as pH 3.5 in 1A to 1C.

Example 5 (present invention): purification of low purity DM

Low purity DM powder of 500 mg (a DM content of 305 mg 30 and a relative purity of 80.3 %) was dissolved in 200 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 4.0), DM was eluted with a methanol-0.1M citric acid buffer solution (pH 4.0) (70 : 30), and the DM-eluted fractions were subjected to HPLC

5 analysis. The DM fractions having relative purities of 86, 88, 89 and 90 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as pH 4.0 in Fig. 1A to 1C. The HPLC analysis charts of low purity DM used as the raw material and a solution obtained by

10 sampling the DM fractions having a relative purity of 88 % or more are shown in Fig. 2 and Fig. 3 respectively.

Example 6 (present invention): purification of low purity DM

Low purity DM powder of 500 mg (a DM content of 305 mg and a relative purity of 80.3 %) was dissolved in 200 ml of acidic

15 water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 4.5), DM was eluted with a methanol-0.1M citric acid buffer solution (pH 4.5) (70 : 30), and the DM-eluted fractions were subjected to HPLC

20 analysis. The DM fractions having relative purities of 86, 88, 89 and 90 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as pH 4.5 in Fig. 1A to 1C.

Example 7 (present invention): purification of low purity DM

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Low purity DM powder of 500 mg (a DM content of 305 mg and a relative purity of 80.3 %) was dissolved in 200 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 5.0), DM was eluted with a methanol-0.1M citric acid buffer solution (pH

30 DM was eluted with a methanol-0.1M citric acid buffer solution (pH
5.0) (70:30), and the DM-eluted fractions were subjected to HPLC

analysis. The DM fractions having relative purities of 86, 88, 89 and 90 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as pH 5.0 in Fig. 1A to 1C.

- 5 Example 8 (present invention): purification of low purity DM Low purity DM powder of 500 mg (a DM content of 305 mg and a relative purity of 80.3 %) was dissolved in 200 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same
- acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 6.0),
 DM was eluted with a methanol-0.1M citric acid buffer solution (pH 6.0) (70 : 30), and the DM-eluted fractions were subjected to HPLC analysis. The DM fractions having relative purities of 86, 88, 89 and 90 % or more were sampled respectively, and the recovering rates,
- the amounts of the recovered solutions and the relative purities of DM are shown as pH 6.0 in Fig. 1A to 1C.
 <u>Example 9</u> (comparative example): purification of raw material DM having a higher purity

Raw material DM powder of 500 mg having a higher

20 purity (a DM content of 463 mg and a relative purity of 95.8 %) was dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of water, DM was eluted with methanol-water (70 : 30), and the DM-eluted fractions

were subjected to HPLC analysis. The DM fractions having relative purities of 96, 97 and 98 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as controls (H20) in Fig. 4A to 4C. <a href="https://www.example.comparative.comparative.

Raw material DM powder of 500 mg having a higher

purity (a DM content of 463 mg and a relative purity of 95.8 %) was dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water, DM was eluted with metha-

5 nol-acidic water (pH 2.5) (70 : 30), and the DM-eluted fractions were subjected to HPLC analysis. The DM fractions having relative purities of 96, 97 and 98 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as controls (pH 2.5) in Fig. 4A to
10 4C.

Example 11 (present invention): purification of raw material DM having a higher purity

Raw material DM powder of 500 mg having a higher purity (a DM content of 463 mg and a relative purity of 95.8 %) was

- 15 dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 2.5), DM was eluted with a methanol-0.1M citric acid buffer solution (pH 2.5) (70 : 30), and the DM-eluted fractions
- 20 were subjected to HPLC analysis. The DM fractions having relative purities of 96, 97 and 98 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as pH 2.5 in Fig. 4A to 4C. <u>Example 12</u> (present invention): purification of raw material DM
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having a higher purity

Raw material DM powder of 500 mg having a higher purity (a DM content of 463 mg and a relative purity of 95.8 %) was dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 3.0), DM was eluted with a methanol-0.1M citric acid buffer solution (pH 3.0) (70 : 30). The DM-eluted fractions having a relative purity of 98 % or more were sampled and subjected to HPLC analysis. The DM fractions having relative purities of 96, 97 and 98 % or more were sampled respectively, and the recovering

5 rates, the amounts of the recovered solutions and the relative purities of DM are shown as pH 3.0 in Fig. 4A to 4C.
 <u>Example 13</u> (present invention): purification of raw material DM having a higher purity

Raw material DM powder of 500 mg having a higher

- 10 purity (a DM content of 463 mg and a relative purity of 95.8 %) was dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 3.5), DM was eluted with a methanol-0.1M citric
- 15 acid buffer solution (pH 3.5) (70 : 30), and the DM-eluted fractions were subjected to HPLC analysis. This experiment was carried out twice. The DM fractions having relative purities of 96, 97 and 98 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM
- 20 are shown as pH 3.5 in Fig. 4A to 4C.
 <u>Example 14</u> (present invention): purification of raw material DM having a higher purity

Raw material DM powder of 500 mg having a higher purity (a DM content of 463 mg and a relative purity of 95.8 %) was

- 25 dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 4.0), DM was eluted with a methanol-0.1M citric acid buffer solution (pH 4.0) (70 : 30), and the DM-eluted fractions
- 30 were subjected to HPLC analysis. This experiment was carried out twice. The DM fractions having relative purities of 96, 97 and 98 %

or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as pH 4.0 in Fig. 4A to 4C.

Example 15 (present invention): purification of raw material DM having a higher purity

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Raw material DM powder of 500 mg having a higher purity (a DM content of 463 mg and a relative purity of 95.8 %) was dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid

buffer solution (pH 4.5), DM was eluted with a methanol-0.1M citric acid buffer solution (pH 4.5) (70 : 30), and the DM-eluted fractions were subjected to HPLC analysis. This experiment was carried out twice. The DM fractions having relative purities of 96, 97 and 98 %

15 or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as pH 4.5 in Fig. 4A to 4C.

Example 16 (present invention): purification of raw material DM having a higher purity

20 Raw material DM powder of 500 mg having a higher purity (a DM content of 463 mg and a relative purity of 95.8 %) was dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid

- 25 buffer solution (pH 5.0), DM was eluted with a methanol-0.1M citric acid buffer solution (pH 5.0) (70 : 30), and the DM-eluted fractions were subjected to HPLC analysis. This experiment was carried out twice. The DM fractions having relative purities of 96, 97 and 98 % or more were sampled respectively, and the recovering rates, the
- 30 amounts of the recovered solutions and the relative purities of DM are shown as pH 5.0 in Fig. 4A to 4C.

Example 17 (present invention): purification of raw material DM having a higher purity

Raw material DM powder of 500 mg having a higher purity (a DM content of 463 mg and a relative purity of 95.8 %) was dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through the HP20 column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 6.0), DM was eluted with a methanol-0.1M citric acid buffer solution (pH 6.0) (70 : 30), and the DM-eluted fractions

10 were subjected to HPLC analysis. The DM fractions having relative purities of 96, 97 and 98 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown as pH 6.0 in Fig. 4A to 4C.
 Example 18 (present invention): purification of raw material DM having a higher purity

Raw material DM powder of 500 mg having a higher purity (a DM content of 463 mg and a relative purity of 95.8 %) was dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through an HP20SS column (50 ml). After washing the

- 20 column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 4.0), DM was eluted with a methanol-0.1M citric acid buffer solution (pH 4.0) (70 : 30), and the DM-eluted fractions were subjected to HPLC analysis. The DM fractions having relative purities of 96, 97, 98 and 99 % or more were sampled
- 25 respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown in the form of a black bar in Fig. 5A to 5C.

Example 19 (present invention): purification of raw material DM having a higher purity

Raw material DM powder of 500 mg having a higher purity (a DM content of 463 mg and a relative purity of 95.8 %) was

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dissolved in 10 ml of acidic water (pH 2.5, HCl), and this solution was passed through he HP20SS column (50 ml). After washing the column with 50 ml of the same acidic water and 100 ml of a 0.1M citric acid buffer solution (pH 4.0), DM was eluted with an acetone-

5 0.1M citric acid buffer solution (pH 4.0) (30 : 70), and the DM-eluted fractions were subjected to HPLC analysis. The DM fractions having relative purities of 96, 97, 98 and 99 % or more were sampled respectively, and the recovering rates, the amounts of the recovered solutions and the relative purities of DM are shown in the form of a void bar in Fig. 5A to 5C.

The HPLC analysis charts of raw material DM having a higher purity used as the raw material and a solution obtained by sampling the DM fractions having a relative purity of 98 % or more are shown in Fig. 6 and Fig. 7 respectively.

15 Example 20 (present invention): recovery of purified DM

DM was recovered from the solution obtained by sampling the DM fractions having a relative purity of 98 % or more in Example 18. The sampled solution was adjusted to a pH of 8.5 with 4N sodium hydroxide, and about a half amount of chloroform based on the

- 20 amount of the solution was added to extract DM. The organic solvent phase containing DM was concentrated and dried under reduced pressure, and then a small amount of chloroform/methanol (20 : 1) was added thereto to dissolve it. This solution was added to an excess amount of hexane, and precipitated DM was filtered and dried
- 25 at 40℃ under reduced pressure for one night. In this case, the resulting DM powder had a yield of 242 mg.

It can be found from the examples described above that according to Fig. 1A to 1C, the method of the present invention can provide the products having a higher relative purity at a higher

30 recovering rate as compared with those of the controls (comparative examples). To be specific, in the comparative example, the fractions

having a relative purity of 89 % or more (black circles and rhomboids) are not obtained, and the fraction having a relative purity of 88 % or more (black quadrangles) has as low recovering rate as 10 % or less, but in the method of the present invention, for example, pH 2.5, the

- 5 fraction having a relative purity of 88 % or more has a recovering rate exceeding 65 %, and the fraction having a relative purity of 89 % or more also has a recovering rate exceeding 10 %. Further, in pH 5.98 according to the present invention, even the fraction having a relative purity of 90 % or more (black rhomboid) has a recovering
- 10 rate exceeding 15 %. These tendencies are observed likewise when acetone is used as the water-miscible organic solvent (refer to Fig. 5A to 5C).

CLAIMS

1. A purifying method of daunomycin characterized by eluting daunomycin from a hydrophobic porous synthetic resin carrier onto which daunomycin is adsorbed from crude daunomycin with an aqueous solution which contains a water-miscible organic solvent and which is buffered to pH 2.5 to 6 and recovering purified daunomycin from the eluent.

2. The purifying method as described in claim 1, wherein the hydrophobic porous synthetic resin carrier onto which crude daunomycin is adsorbed is prepared by contacting a solution obtained by dissolving crude daunomycin in an acidic aqueous solution having a pH of about 1 to 5 with the hydrophobic porous synthetic resin carrier to thereby adsorb daunomycin on said carrier and then washing the resin carrier adsorbing daunomycin with said acidic aqueous solution.

3. The purifying method as described in claim 2, wherein said acidic aqueous solution used for washing the carrier adsorbing daunomycin is buffered.

4. The purifying method as described in any of claims 1 to 3, wherein the buffered aqueous solution containing the organic solvent is buffered with a citric acid buffer solution, and said organic solvent is at least one solvent selected from the group consisting of methanol, ethanol and acetone.

5. The purifying method as described in claim 4, wherein said buffered aqueous solution containing the organic solvent has a volume ratio of the organic solvent to the aqueous solution of 80 : 20 to 20 : 80.

6. The purifying method as described in any of claims 1 to 5, wherein crude daunomycin has a relative purity of 80 to 96 %.

ABSTRACT

The present invention relates to a method in which daunomycin is eluted from a hydrophobic porous synthetic resin carrier onto which daunomycin is adsorbed from crude daunomycin with a buffered aqueous solution containing a water-miscible organic solvent to recover purified daunomycin. Daunomycin (daunorubicin) is purified efficiently.

Fig. 1A







Fig. 1C







Fig. 3



Fig. 4A





















